

**Electronic supplementary information for
Synthesis and characterization of surface ion-imprinted polymer based
on SiO₂-coated graphene oxide for selective adsorption of uranium(VI)**

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Table S1 Kinetic parameters for the U(VI) adsorption onto GO/SiO₂-IIP

Pseudo-first order			Pseudo-second order		
Q _{e1} (mg g ⁻¹)	k ₁ (min ⁻¹)	R ²	Q _{e2} (mg g ⁻¹)	k ₂ (g mg ⁻¹ min ⁻¹)	R ²
0.0169	0.117	0.8928	1.120	386.99	0.9928

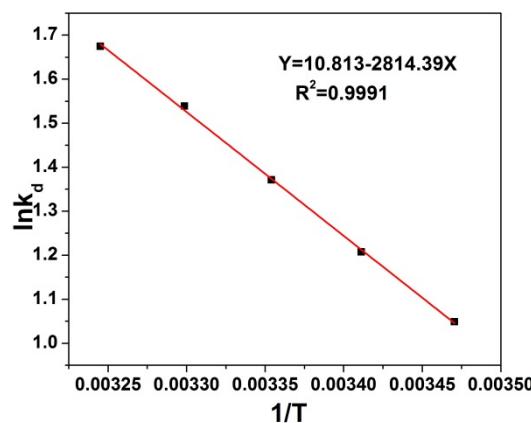


Fig. S1 Plot of lnK_d vs. 1/T for the uptake of U(VI) on GO/SiO₂-IIP (C₀=5 mg L⁻¹, pH=4.0, t = 7min, W = 10mg and V =20 mL).

Table S2 Langmuir and Freundlich isotherm parameters for sorption of U(VI) by GO/SiO₂-IIP and GO/SiO₂-NIP

	Langmuir model			Freundlich model		
	K _L (L g ⁻¹)	Q _m (mg g ⁻¹)	R ²	k _F	n	R ²
GO/SiO ₂ -IIP	0.1886	17.89	0.9982	5.889	4.031	0.9782
GO/SiO ₂ -NIP	0.0794	10.32	0.9968	1.877	2.758	0.9787

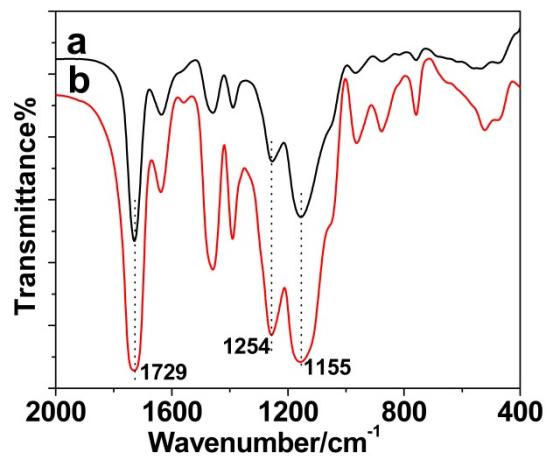


Fig. S2 FT-IR spectra of GO/SiO₂-IIP (a) and GO/SiO₂-IIP after five adsorption-desorption cycles (b).